4M High Speed SRAM (1-Mword × 4-bit)

HITACHI

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Description

The HM62W4100H is a 4-Mbit high speed static RAM organized 1-Mword \times 4-bit. It has realized high speed access time by employing CMOS process (4-transistor + 2-poly resistor memory cell) and high speed circuit designing technology. It is most appropriate for the application which requires high speed and high density memory, such as cache and buffer memory in system. The HM62W4100H is packaged in 400-mil 32-pin SOJ for high density surface mounting.

Features

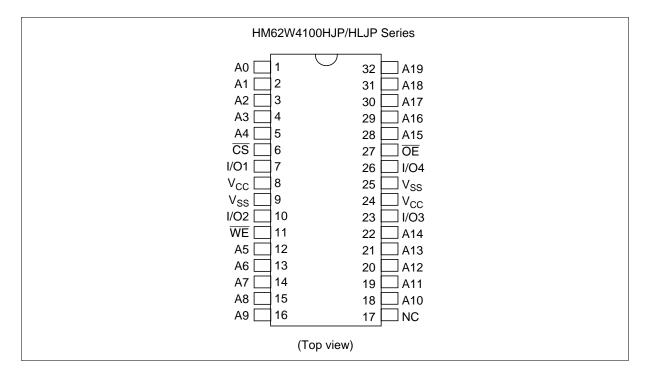
- Single supply : $3.3 \text{ V} \pm 0.3 \text{ V}$
- Access time 12/15 ns (max)
- Completely static memory
 No clock or timing strobe required
- Equal access and cycle times
- Directly TTL compatible
 - All inputs and outputs
- Operating current : 180/160 mA (max)
- TTL standby current : 60/50 mA (max)
- CMOS standby current : 5 mA (max)
 - : 1 mA (max) (L-version)
- Data retension current : 0.6 mA (max) (L-version)
- Data retension voltage: 2 V (min) (L-version)
- Center V_{CC} and V_{ss} type pinout



Ordering Information

Туре No.	Access time	Package
HM62W4100HJP-12	12 ns	400-mil 32-pin plastic SOJ (CP-32DB)
HM62W4100HJP-15	15 ns	
HM62W4100HLJP-12	12 ns	
HM62W4100HLJP-15	15 ns	

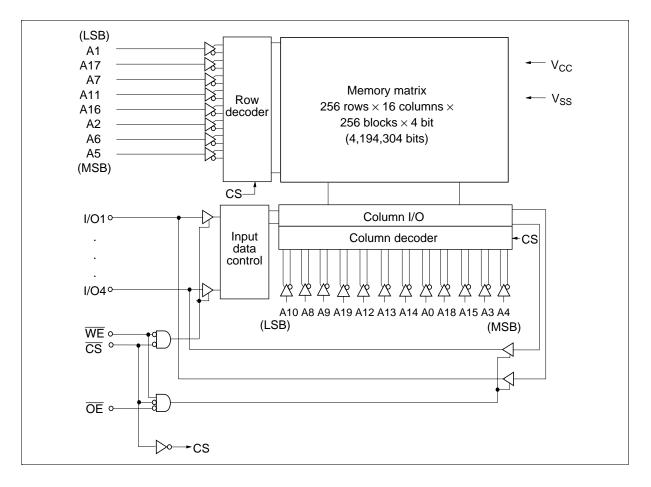
Pin Arrangement



Pin Description

Pin name	Function
A0 to A19	Address input
I/O1 to I/O4	Data input/output
CS	Chip select
ŌĒ	Output enable
WE	Write enable
V _{cc}	Power supply
V _{ss}	Ground
NC	No connection

Block Diagram



Operation Table

CS	OE	WE	Mode	V _{cc} current	I/O	Ref. cycle
Н	×	×	Standby	I_{SB},I_{SB1}	High-Z	_
L	Н	Н	Output disable	I _{cc}	High-Z	_
L	L	Н	Read	I _{cc}	Dout	Read cycle (1) to (3)
L	Н	L	Write	I _{cc}	Din	Write cycle (1)
L	L	L	Write	I _{cc}	Din	Write cycle (2)

Note: X: H or L

Absolute Maximum Ratings

Parameter	Symbol	Value	Unit
Supply voltage relative to V_{ss}	V _{cc}	-0.5 to +4.6	V
Voltage on any pin relative to V_{ss}	V _T	-0.5^{*1} to V _{cc} +0.5 ^{*2}	V
Power dissipation	P _T	1.0	W
Operating temperature	Topr	0 to +70	°C
Storage temperature	Tstg	-55 to +125	°C
Storage temperature under bias	Tbias	-10 to +85	°C

Notes: 1. V_{τ} (min) = -2.0 V for pulse width (under shoot) ≤ 8 ns

2. V_{T} (max) = V_{CC} + 2.0 V for pulse width (over shoot) \leq 8 ns

Recommended DC Operating Conditions (Ta = 0 to $+70^{\circ}$ C)

Parameter	Symbol	Min	Тур	Max	Unit
Supply voltage	V _{cc} * ³	3.0	3.3	3.6	V
	V _{ss} *4	0	0	0	V
Input voltage	V _{IH}	2.2	·	$V_{cc} + 0.5^{*2}$	V
	V _{IL}	-0.5*1		0.8	V

Notes: 1. V_{IL} (min) = -2.0 V for pulse width (under shoot) \leq 8 ns

2. V_{IH} (max) = V_{CC} + 2.0 V for pulse width (over shoot) \leq 8 ns

3. The supply voltage with all $V_{\rm cc}$ pins must be on the same level.

4. The supply voltage with all V_{ss} pins must be on the same level.

Parameter		Symbol	Min	Typ*1	Max	Unit	Test conditions
Input leakage current		ll _u l	—	—	2	μΑ	Vin = V_{ss} to V_{cc}
Output leakage current		II _{LO} I		_	2	μA	Vin = V_{ss} to V_{cc}
Operation power supply current	12 ns cycle	I _{cc}			180	mA	$\frac{\text{Min cycle}}{\text{CS}} = V_{\text{IL}}, \text{ lout} = 0 \text{ mA}$ Other inputs = $V_{\text{IH}}/V_{\text{IL}}$
	15 ns cycle	I _{cc}		_	160		
Standby power supply current	12 ns cycle	I _{SB}		—	60	mA	Min cycle, $\overline{CS} = V_{IH}$, Other inputs = V_{IH}/V_{IL}
	15 ns cycle	I _{SB}	_	—	50		
		I _{SB1}	_	0.05	5	mA	
			<u>*</u> 2	0.05*2	1* ²		
Output voltage	0	V _{oL}	_		0.4	V	I _{oL} = 8 mA
		V _{OH}	2.4	_	_	V	$I_{OH} = -4 \text{ mA}$

DC Characteristics (Ta = 0 to +70°C, V_{CC} = 3.3 V ± 0.3 V, V_{SS} = 0V)

Notes: 1. Typical values are at V_{cc} = 3.3 V, Ta = +25°C and not guaranteed.

2. This characteristics is guaranteed only for L-version.

Capacitance (Ta = $+25^{\circ}$ C, f = 1.0 MHz)

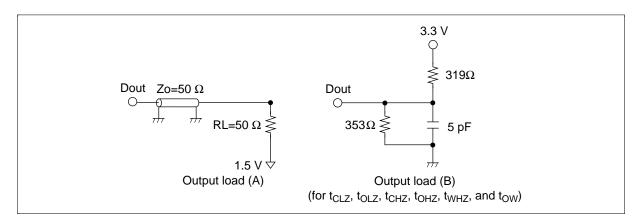
Parameter	Symbol	Min	Тур	Max	Unit	Test conditions
Input capacitance*1	Cin	_	_	6	pF	Vin = 0 V
Input/output capacitance*1	C _{I/O}	_		8	pF	V _{I/O} = 0 V

Note: 1. This parameter is sampled and not 100% tested.

AC Characteristics (Ta = 0 to +70°C, V_{CC} = 3.3 V ± 0.3 V, unless otherwise noted.)

Test Conditions

- Input pulse levels: 3.0 V/0.0 V
- Input rise and fall time: 3 ns
- Input and output timing reference levels: 1.5 V
- Output load: See figures (Including scope and jig)



Read Cycle

		HM62W4100H					
		-12		-15			
Parameter	Symbol	Min	Max	Min	Max	Unit	Notes
Read cycle time	t _{RC}	12	_	15	—	ns	
Address access time	t _{AA}		12		15	ns	
Chip select access time	t _{ACS}		12		15	ns	
Output enable to outpput valid	t _{oe}	_	6		7	ns	
Output hold from address change	t _{oH}	3		3	_	ns	
Chip select to output in low-Z	t _{cLZ}	3	_	3	_	ns	1
Output enable to output in low-Z	t _{oLZ}	0		0	_	ns	1
Chip deselect to output in high-Z	t _{cHZ}	_	6	_	7	ns	1
Output disable to output in high-Z	t _{oHz}	_	6	_	7	ns	1

Write Cycle

		HM62	W4100H					
		-12		-15				
Parameter	Symbol	Min	Max	Min	Max	Unit	Notes	
Write cycle time	t _{wc}	12	_	15		ns		
Address valid to end of write	t _{AW}	8	_	10	_	ns		
Chip select to end of write	t _{cw}	8		10		ns	9	
Write pulse width	t _{wP}	8		10		ns	8	
Address setup time	t _{AS}	0		0		ns	6	
Write recovery time	t _{wR}	0		0		ns	7	
Data to write time overlap	t _{DW}	6	·	7		ns		
Data hold from write time	t _{DH}	0	_	0		ns		
Write disable to output in low-Z	t _{ow}	3		3		ns	1	
Output disable to output in high-Z	t _{oHz}	_	6	_	7	ns	1	
Write enable to output in high-Z	t _{wHZ}		6		7	ns	1	

Note: 1. Transition is measured ±200 mV from steady voltage with Load (B). This parameter is sampled and not 100% tested.

2. Address should be valid prior to or coincident with $\overline{\text{CS}}$ transition low.

3. $\overline{\text{WE}}$ and/or $\overline{\text{CS}}$ must be high during address transition time.

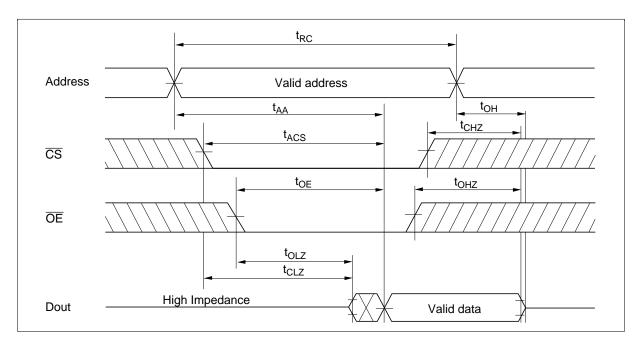
 if CS and OE are low during this period, I/O pins are in the output state. Then, the data input signals of opposite phase to the outputs must not be applied to them.

- If the CS low transition occurs simultaneously with the WE low transition or after the WE transition, output remains a high impedance state.
- 6. t_{AS} is measured from the latest address transition to the later of \overline{CS} or \overline{WE} going low.
- 7. t_{WR} is measured from the earlier of \overline{CS} or \overline{WE} going high to the first address transition.
- 8. A write occurs during the overlap of a low CS and a low WE. A write begins at the latest transition among CS going low and WE going low. A write ends at the earliest transition among CS going high and WE going high. t_{wP} is measured from the beginning of write to the end of write.

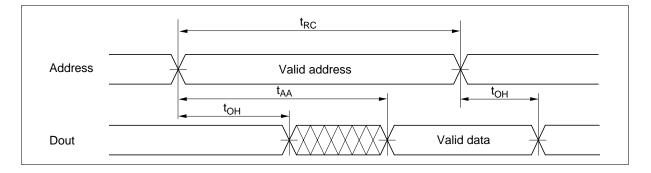
9. t_{cw} is measured from the later of \overline{CS} going low to the the end of write.

Timing Waveforms

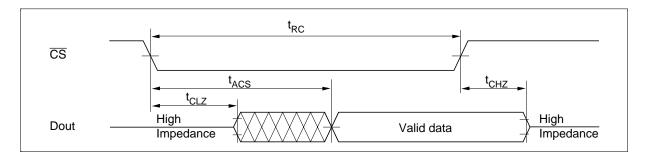
Read Timing Waveform (1) $(\overline{WE}=V_{\rm IH})$



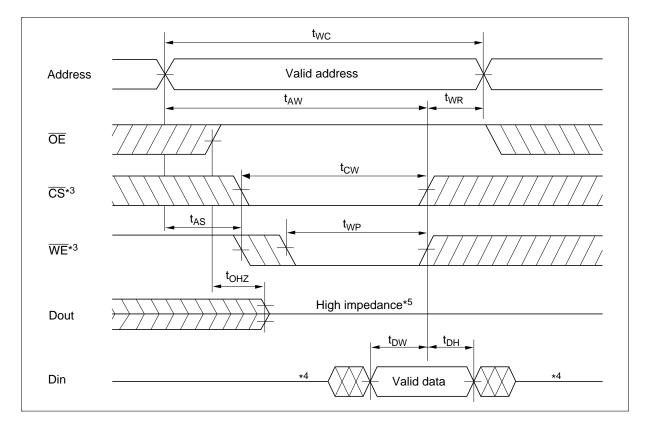
Read Timing Waveform (2) ($\overline{WE} = V_{II}$, $\overline{CS} = V_{IL}$, $\overline{OE} = V_{IL}$)

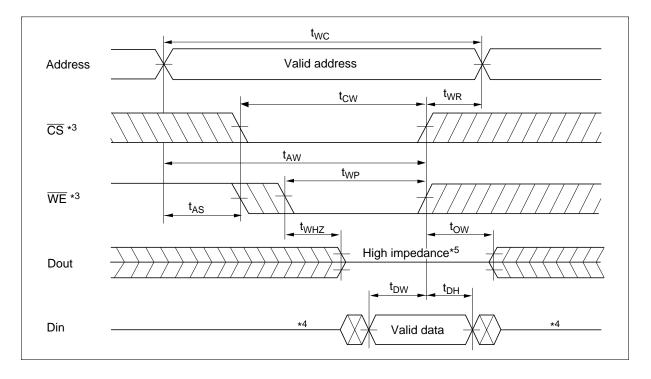


Read Timing Waveform (3) $(\overline{WE} = V_{IH}, \overline{CS} = V_{IL}, \overline{OE} = V_{IL})^{*2}$



Write Timing Waveform (1) (WE Controlled)





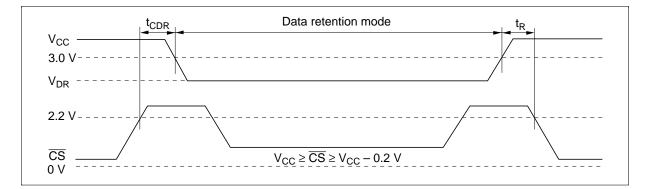
Write Timing Waveform (2) ($\overline{\text{CS}}$ Controlled)

Low V_{cc} Data Retention Characteristics (Ta = 0 to +70°C)

This characteristics is guaranteed only for L-version.

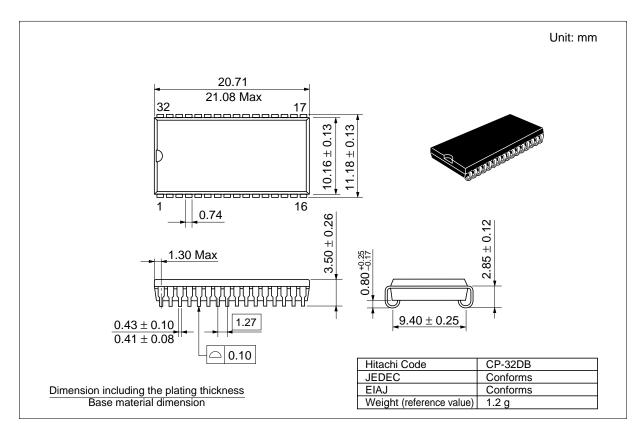
Parameter	Symbol	Min	Typ*1	Max	Unit	Test conditions	
V_{cc} for data retention	V_{DR}	2.0	—	—	V	$\begin{array}{l} V_{cc} \geq \overline{CS} \geq V_{cc} - 0.2 \ V \\ \textbf{(1)} 0 \ V \leq Vin \leq 0.2 \ V \ or \\ \textbf{(2)} V_{cc} \geq Vin \geq V_{cc} - 0.2 \ V \end{array}$	
Data retention current	I _{CCDR}		40	600	μA	$\begin{array}{l} V_{cc} = 3 \; V, \; V_{cc} \geq \overline{CS} \geq V_{cc} - 0.2 \; V \\ (1) \; \; 0 \; V \leq Vin \leq 0.2 \; V \; or \\ (2) \; \; V_{cc} \geq Vin \geq V_{cc} - 0.2 \; V \end{array}$	
Chip deselect to data retention time	t_{CDR}	0	_	—	ns	See retention waveform	
Operation recovery time	t _R	5		_	ms	_	
Note: 1. Typical values are at $V_{cc} = 3.0 \text{ V}$, Ta = +25°C, and not guaranteed.							

Low V_{CC} Data Retention Timing Waveform



Package Dimensions

HM62W4100HJP/HLJP Series (CP-32DB)



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